Approved For Release 2004/08/31: CIA-RDP85B00803R000100040001-9

EKC CONTRAXT XXXX EB-1592 Cut=off date 16 April 1967.

25X1

For researc	h and	development		
Approx		obligated	from	inception.

Originated to cover field of photosensitive emulsions, processing and printing equipment and techniques related thereto.

NRO review(s) completed.